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REPLY UNDER 37 CFR 1.116
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/707,388

Conf. No.: 1387

Filing Date: 12/10/2003

Art Unit: 2891

Applicant: Divakaruni et al.

Examiner: Fulk, Steven J.

Title: SILICIDE RESISTOR IN BEOL LAYER
OF SEMICONDUCTOR DEVICE AND METHOD

Docket No.: FIS920030274
(IBMF-0032)

COMMISSIONER FOR PATENTS

DESTINATION FACSIMILE NUMBER: 571-273-8300

Transmitted herewith is:

After-Final Amendment in 10 pages

in the above identified application.

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In Re Application of: Divakaruni et al.

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Title: SILICIDE RESISTOR IN BEOL
LAYER OF SEMICONDUCTOR
DEVICE AND METHOD

Examiner: Fulk, Steven J.

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AFTER-FINAL REQUEST FOR RECONSIDERATION

Sir:

I. INTRODUCTORY COMMENTS:

In response to the final Office Action of November 10, 2005, please reconsider the above-referenced patent application as follows: